

PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10005803	FILING DATE 12/05/2001	CLASS 438	SUBCLASS 7	GAU 1765	EXAMINER n(n, k)
----------------------	---------------------------	--------------	---------------	-------------	---------------------

**APPLICANTS: Shih Hsin-Ching Su Jen Li Te, Chiao Li-Chieh

**CONTINUING DATA VERIFIED:

** FOREIGN APPLICATIONS VERIFIED:

PG-PUB	DO NOT PUBLISH <input checked="" type="checkbox"/>	RESCIND <input type="checkbox"/>	ATTORNEY DOCKET NO
Foreign priority claimed 35 USC 119 conditions met	✓ yes <input type="checkbox"/> no <input type="checkbox"/>		TSC1 663
Verified and Acknowledged Examiner's initials			
TITLE : Dry-wet-dry solvent-free process after stop layer etch in dual damascene process			

NOTICE OF ALLOWANCE MAILED		Assistant Examiner	CLAIMS ALLOWED	
Amount Due	Date Paid		Total Claims	Print Claim for O.G
ISSUE FEE		Primary Examiner	DRAWING	
			Sheets Draw.	Figs. Draw.
TERMINAL DISCLAIMER		Application Examiner		
PREPARED FOR ISSUE				
WARNING: The information disclosed herein may be restricted. Unauthorized disclosure may be prohibited by the United States Code Title 35, Sections 122, 181 and 368. Possession outside the U.S. Patent & Trademark Office is restricted to authorized employees and contractors only.				

FILED WITH:

DISK (CRF)

CD-ROM
(Attached in pocket on right inside flap)